



This project has received funding from the European Union's Horizon 2020 Research and Innovation programme under GA No 101004730.

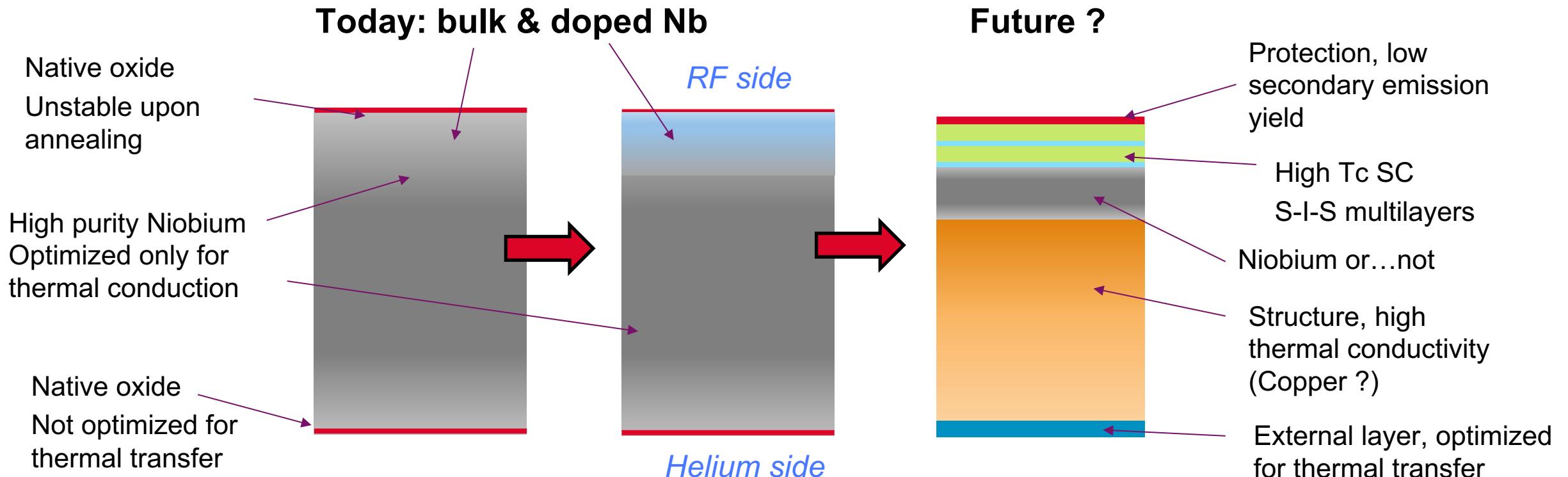
Thin films activities in the IFAST program

eeFACT 2022

Claire Antoine (CEA)



Desired: Tailored material for RF cavities

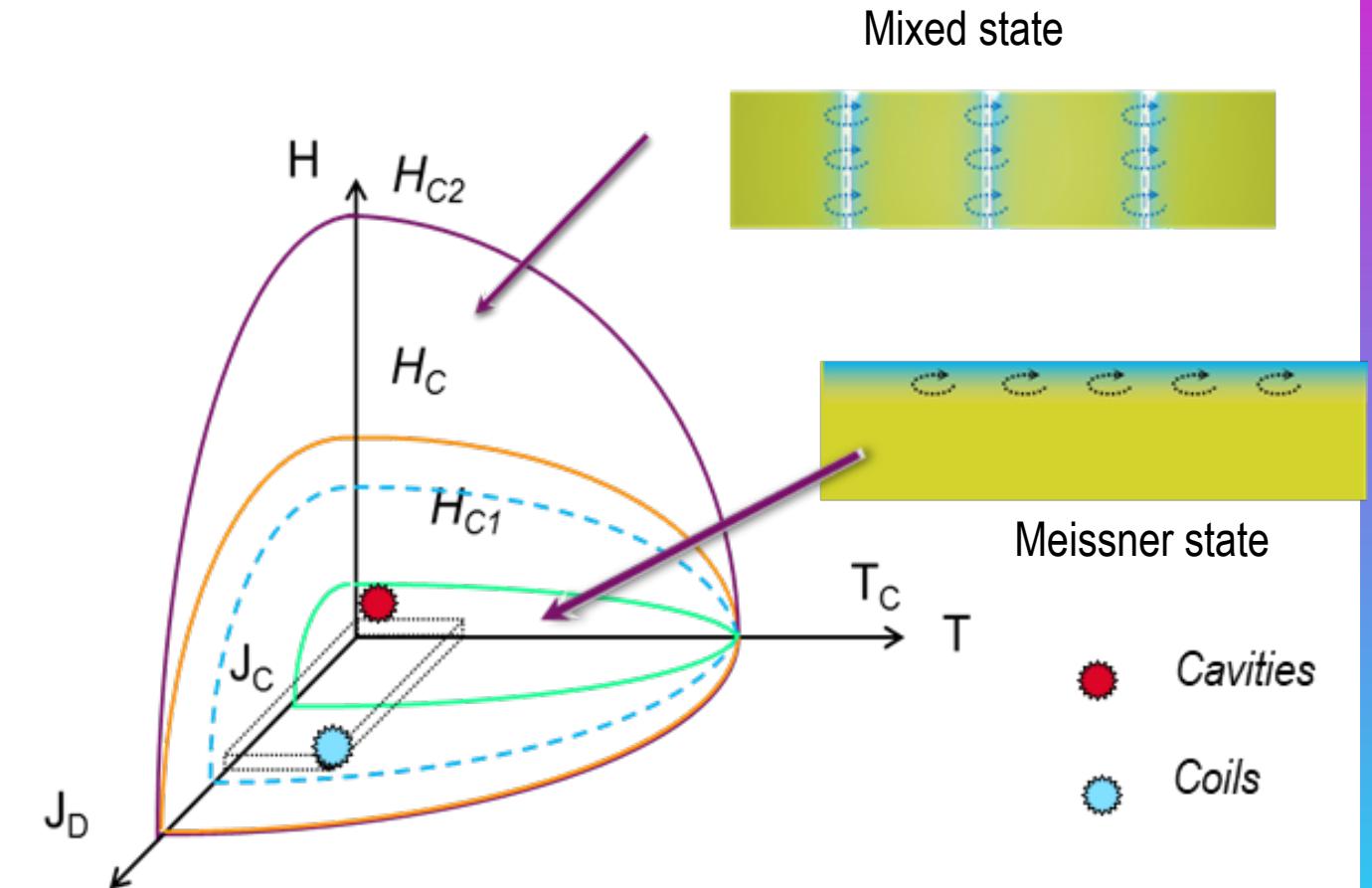


At stakes : COST REDUCTION !!!

- Cooling power (any application); can we go to cryocooling ?
- High accelerating fields => shorter machines ?

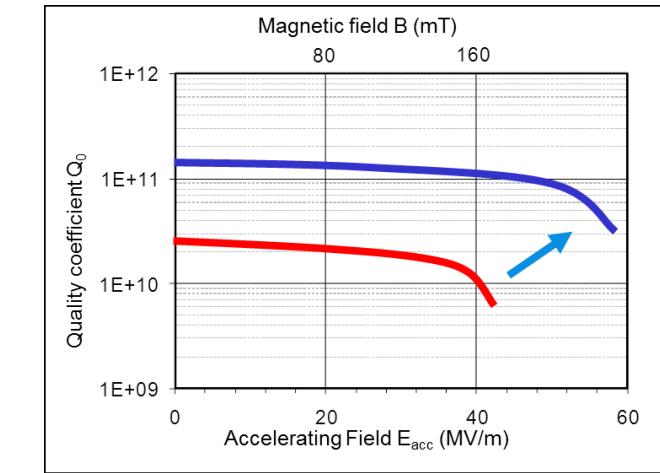
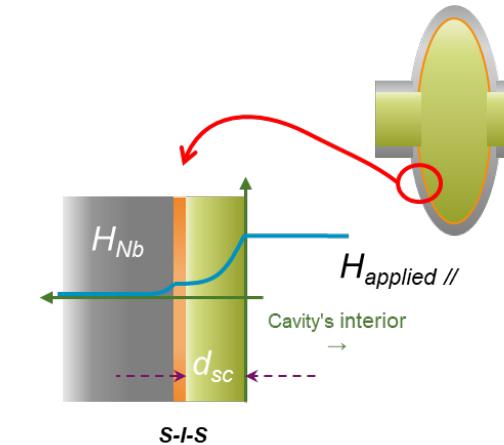
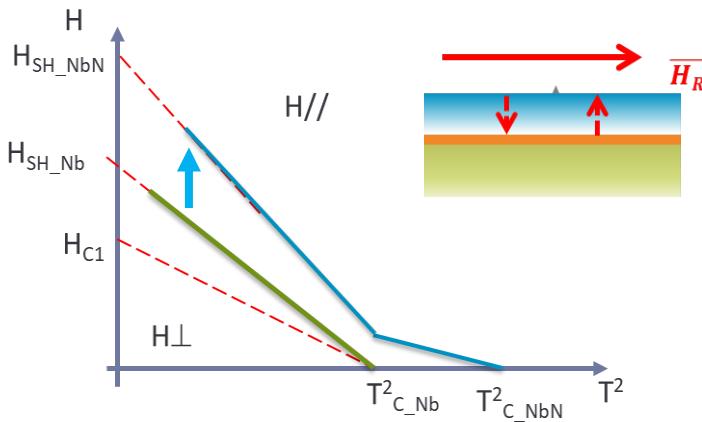
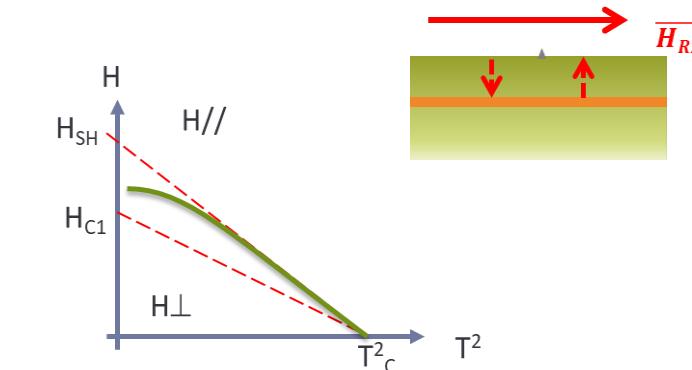
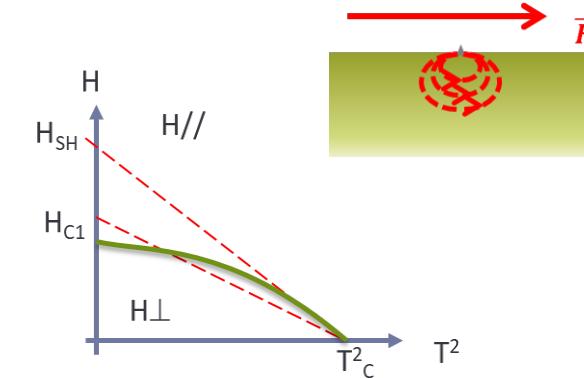
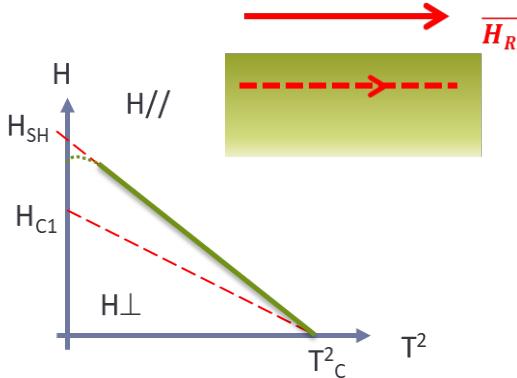
Superconductivity recalls

- \exists thousands of SC
- In practice:
 - <10 are actually used
 - They are all type II
- Type II SC : 3 main Phases
 - Meissner state (SC, $B=0$)
 - Mixed state (SC + vortices ($B \neq 0$))
 - Normal conducting State
- Applications...
 - All applied SC are type II: i.e. low H_{C1} and high $H_{C2} \Rightarrow$ operate in mixed state...
 - EXCEPT Nb for RF application !!!

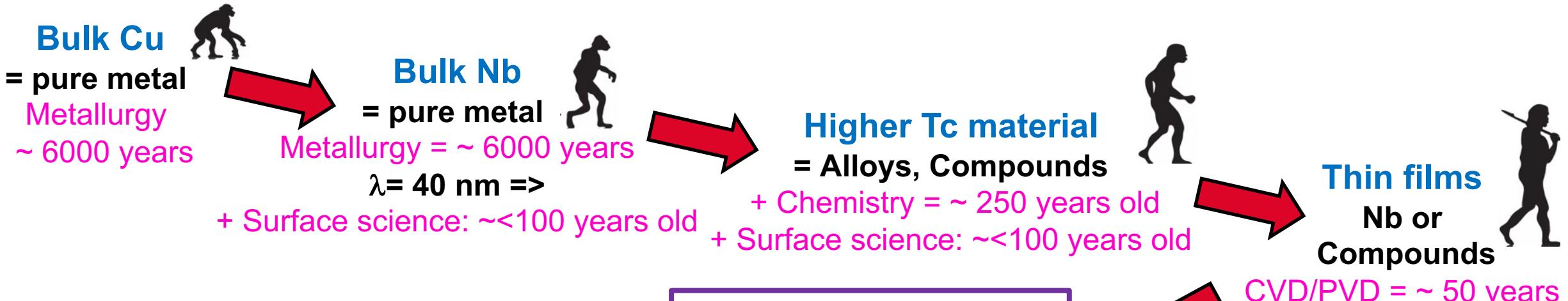


Multilayers (SIS) concept, or how to make theory face reality

*For the recall SRF cavity must operate in Meissner state !
No flux line please !*



Some historical recalls about RF technology



Improving RF technology:

- Huge challenges in material science
- Vast parameter space to be explored
- Underfinanced for years:
 - Accelerators considered as dirty hardware by fundamental material scientists
 - Material science considered as alchemy by (most) accelerator scientists

Most developments,
though, financed by
Accelerator Community

Not enough
(compared to e.g.
magnet history)

Objectives for WP9 (task9.1)

Innovative superconducting cavities

Improve performance and reduce cost of SRF acceleration systems

- We aim at building **together** a **global strategy** to be able to produce Superconducting RF (SRF) cavities coated with a superconducting films. **Not only IFast, (informal) WW collaboration**
- It includes pursuing the **optimization** and the **industrialization**:
 - **Substrates preparation (Nb, Cu)**, e.g. *PEP, metallographic polishing*
 - Pre-and post treatment (*laser, flash annealing*)
 - The production of **seamless copper cavities**
 - The optimization **deposition techniques**: **MS, PVD, ALD...** to get **Nb, NbN, Nb₃Sn, V₃Si...** thick films (μm) and/or **SIS Multilayers (nm)**
- Produce and RF test prototypes of SRF cavities at 6 GHz: **Easier to fabricate, handle, dissect to provide fast feedback**
- Produce accelerator type 1.3 GHz cavities (**feasibility assessment**).

Task 9.2: Seamless elliptical copper cavities

Task Leader: Cristian Pira (INFN)

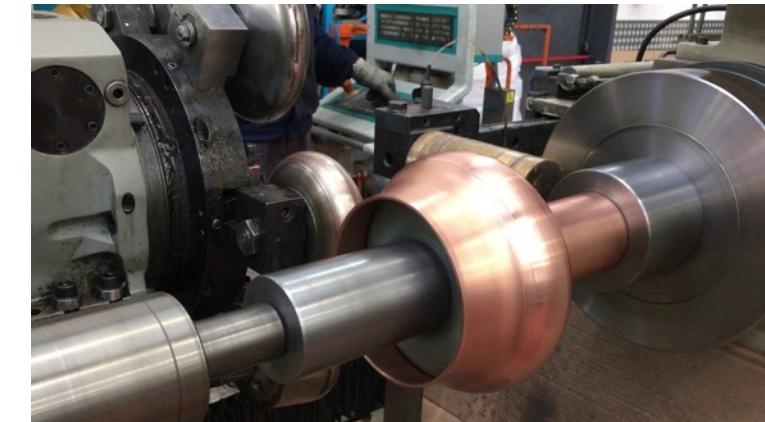


GOALS:

- Move cavity forming process from semi-automatic to fully automatic using CNC machine
- 6 GHz for task 9.3 and 1.3 GHz cavities for prototypes

WHY ?

- Need a lot of cavities for destructive tests
- Welding on copper definitively bad for films
- 18 cavities realized 6 GHz , 1 @ 1,3,GHz



Automatic spinning machine @
PICCOLI

Task 9.3 Part 1: Cavity Coating and Evaluation

Task Leader: Reza Valizadeh (UKRI)

GOALS:

- Quick deposition, quick testing, low cost (6 GHz)
- Optimization of process parameters with A15 material
- Evaluation of SRF performance by deposition of high T_c superconductor inside a 6-GHz copper cavity:

Nb₃Sn, NbTiN, NbN, MgB₂

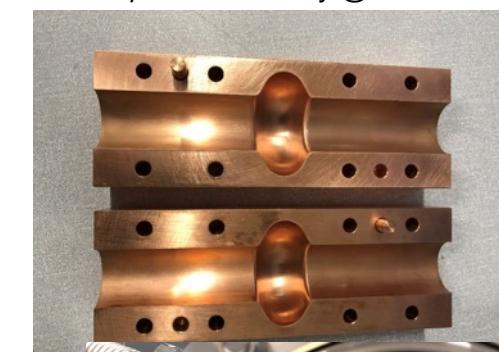
WHY?

- Higher T_c SC are complex (compound) materials
- Composition needs to be adjusted to get best SRF performance
- Optimized recipes need then to be adapted for complex geometries

INFN 6 GHz cavity



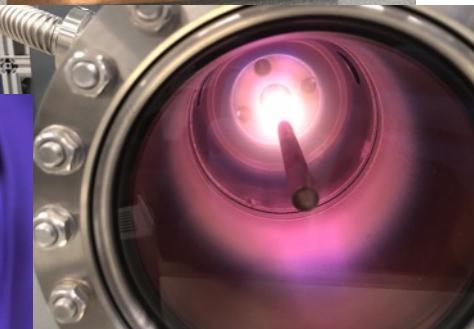
Open 6 GHz cavity @ UKRI



Nb₃Sn 4" planar magnetron source @L



Nb magnetron target@ UKRI



Sputtering system @ USie

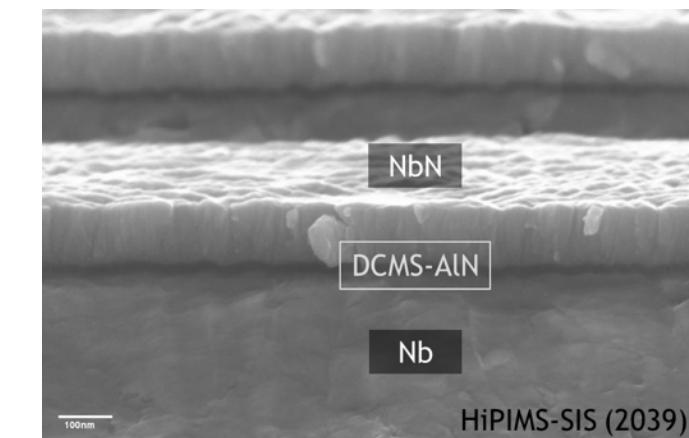
Task 9.3 Part Two: Planar Samples & QPR deposition

GOAL:

- Optimise deposition parameters for other high T_c superconductor and provide sample for other partners for RF evaluation of their Thin Films

WHY ?

- Optimization of films still on going
- Alternative surface treatments
- Need to assess RF properties (see Task 9.6)
- Going from flat sample to complex shaped cavities is not straightforward
=> intermediate step



HiPIMS-coated SIS structure on Si



Task 9.4: Surface engineering by atomic layer deposition (ALD)

Task Leader: Thomas Proslier(CEA)

GOAL:

- Deposition of functionalized layers :
 - Low secondary yield cap layer (\downarrow multipacting)
 - SIS multilayers
 - Dielectric surface engineering and doping
- Development of a 1.3 GHz deposition set-up

WHY ?

- ALD = highly conformational
 - => adapted to complex shapes
- Chemical technique
 - => wide range of compounds manageable in the same deposition set-up => in situ composite fabrication
- Can be used to upgrade Bulk Nb cavities



Principle

- Chemical precursors (gaz)
- Precursor 1 : adsorbed (chemisorbed) on the surface
- Purge (neutral gas): only 1 monolayer @ surface
- Precursor 2 : reacts w. precursor 1 directly on the surface => adapted to complex shapes like cavities (no line of sight issues)

Task 9.4 results summary

Achievements :

- Control and reduction by ALD of the secondary electron yield and the resulting multipacting mitigation.
- Control and optimization of the superconducting multilayer properties by ALD ($T_c = 15K$).
- Homogeneous deposition and multilayer properties on Nb and Cu 1.3 GHz cavities.
- Compatible with cavity surface treatments (stability after HPR, thermal treatments...)
- New doping approach and dielectric layer engineering by ALD for bulk Nb.



New ALD system @CEA
Soon ready for 1.3 GHz cavity deposition
Compatible w. 700 MHz cavities

Atomic Layer deposition strength is its scalable capability: from bench to industrial scale (coupons to cavities and much more high aspect ratio and large surface objects).

Task 9.5: Improvement of mechanical and superconducting properties of RF resonator by laser radiation

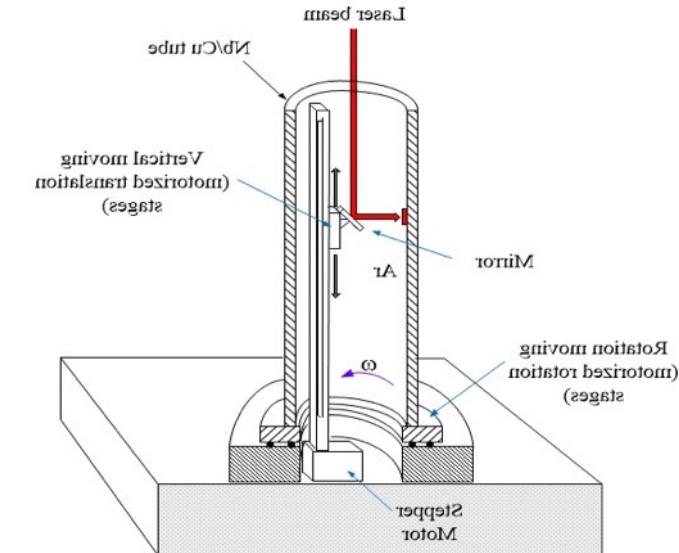
Task Leader: Arturs Medvids (RTU)

GOAL:

- Pre-and Post-surface Laser treatment
 - On copper, to improve film deposition
 - On deposited films, to improve their crystalline quality

WHY ?

- Smoothing of surfaces
- Recrystallization
- Adhesion
- Decreasing porosities



Laser	FLA	RTA	FA
ns	ms	s	min-h



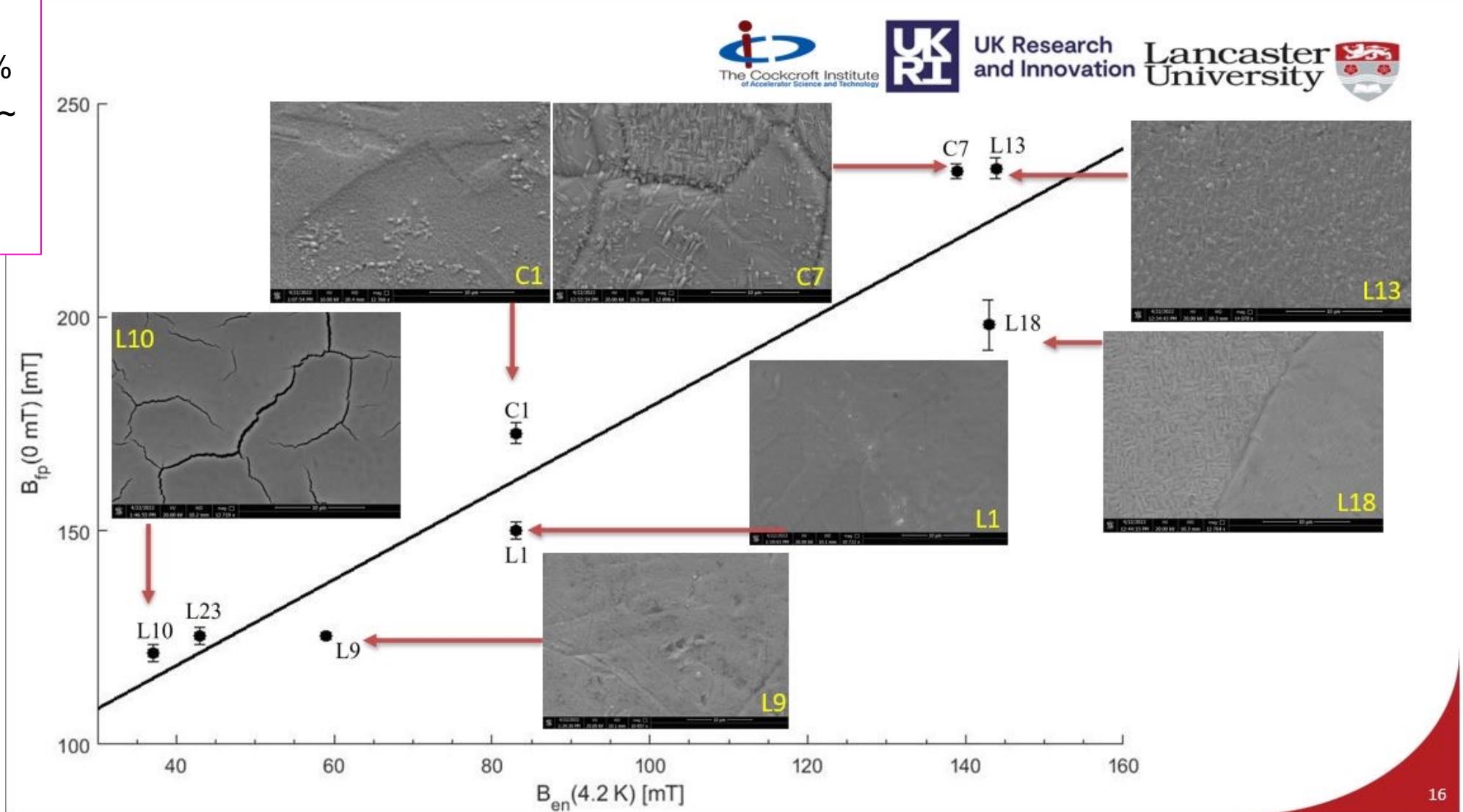
*FLAsh lamp annealing :
New development w. HZDR*

Assessment of the efficiency of laser treatment

<https://indico.cern.ch/event/1140002/contributions/4783615/attachments/2436059/4172593/iFAST.WP9.5th.DTurner.FPE.pdf>

Best Nb/Cu:

- Crystal size $\uparrow \sim 20\%$
- Adhesion Nb/Cu $\uparrow \sim 36\%$
- Roughness divided by $>\sim 2$



Task 9.6: Optimization of flat SRF thin films production procedure

Task Leader: Oliver Kugeler (HZB)

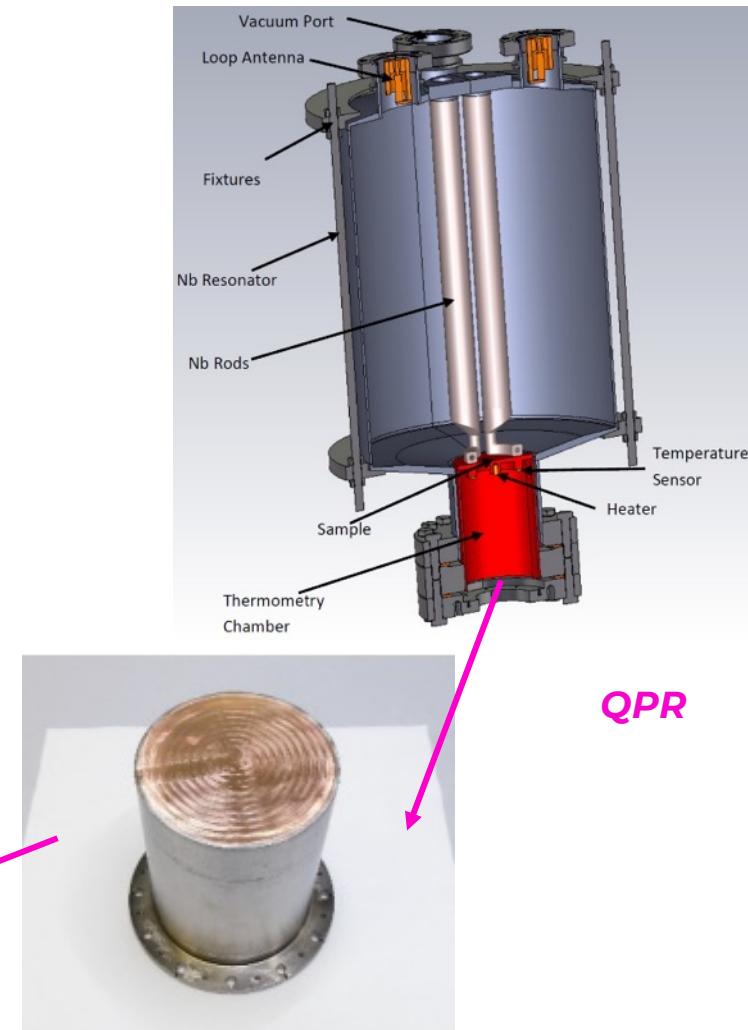
GOAL:

- RF testing of the films developed throughout the WP9
 - Sample is small enough for easy handling
 - Sample is flat (one problem less in the way)
 - 3 ≠ frequencies available : large exploration (R_{BCS} vs R_{res})

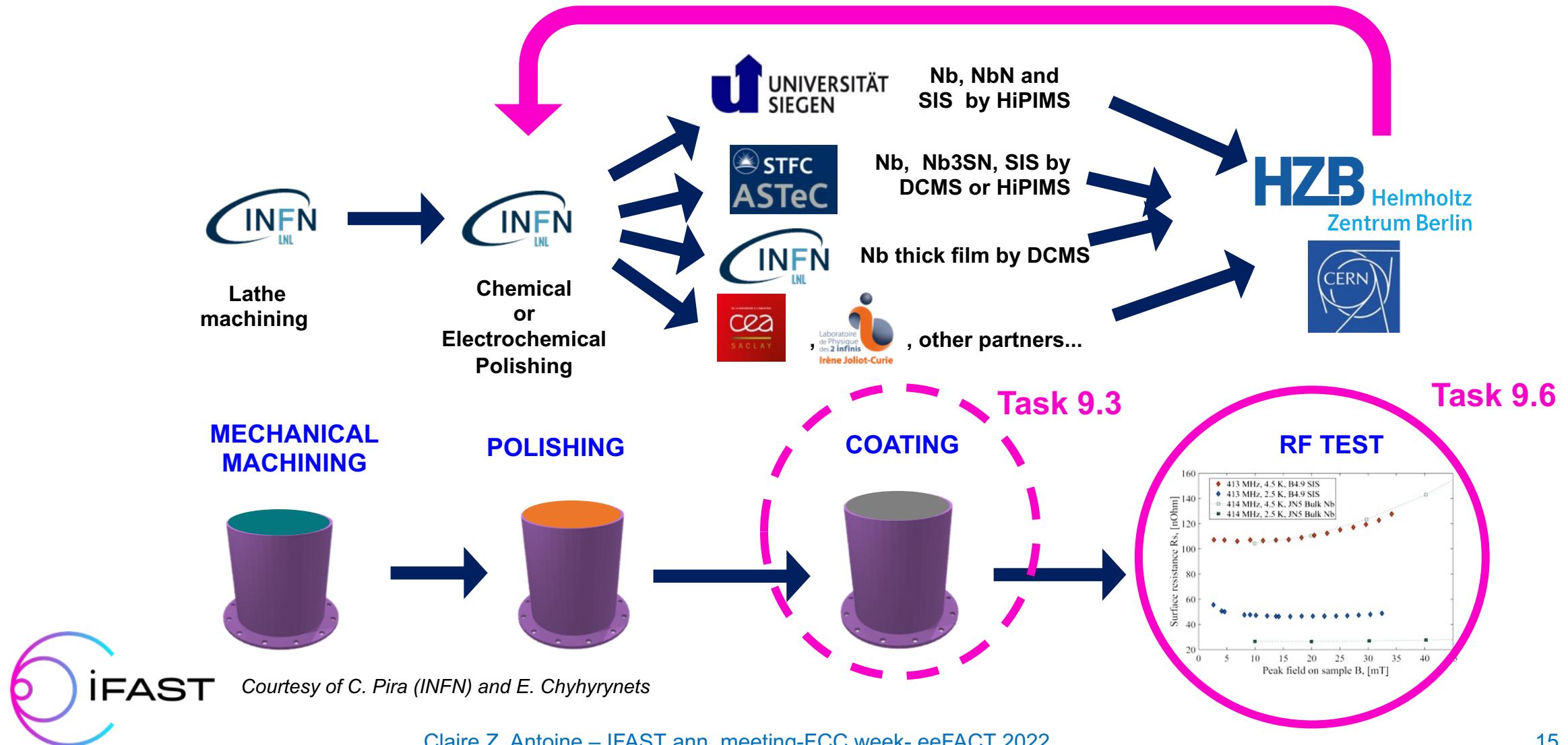
WHY ?

- Material characterization, even advanced are still not predictive of future RF behavior

Flat sample for RF testing



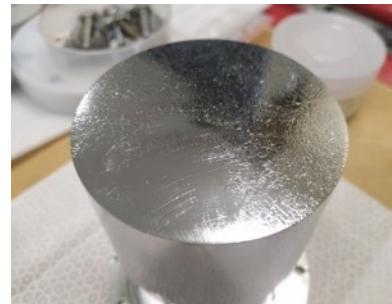
Task 9.6: Optimization of flat SRF thin films production procedure



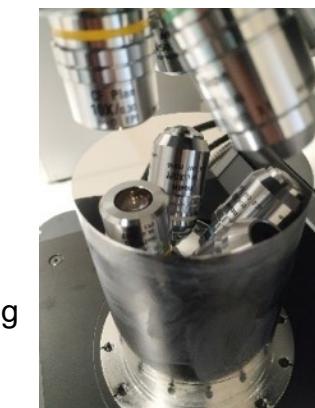
Task 9.6: Baseline measurement on QPR samples

Metallographic polishing @ CEA/IJCLab

QPR sample milled from ASTM0 large grain material
Poor RF performance,
In contaminations

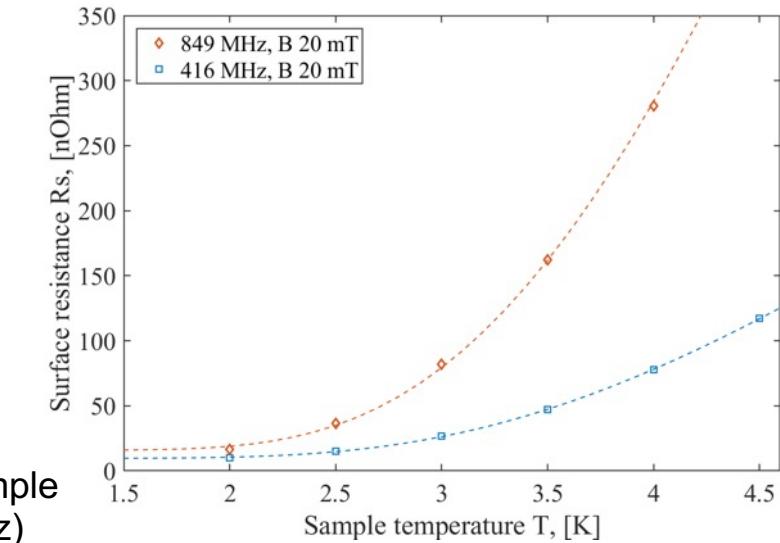


Pictures courtesy Oleksandr Hryhorenko (IJCLab)

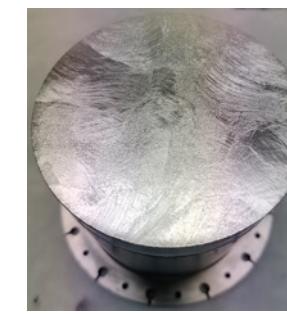
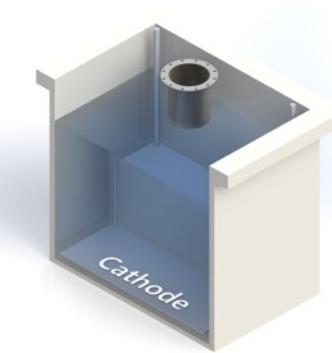


Mirror polishing
at IJCLab

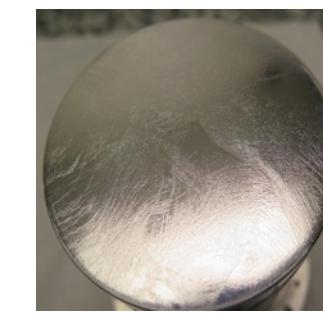
Great RF performance of baseline sample
(9 Ohm residual resistance at 416 MHz)



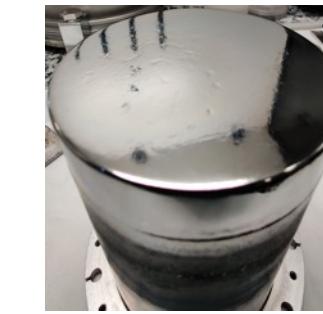
Plasma electropolishing samples@ INFN



Initial Nb QPR sample



Surface improvement after 10 min



100-μm removal in 60 min.
Mirror finish

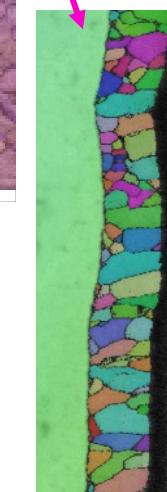
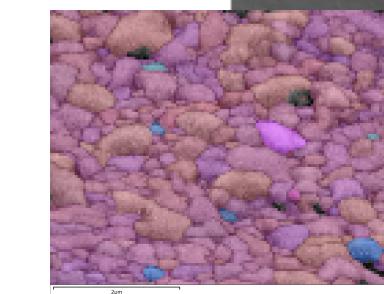
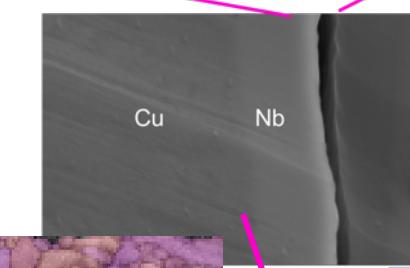
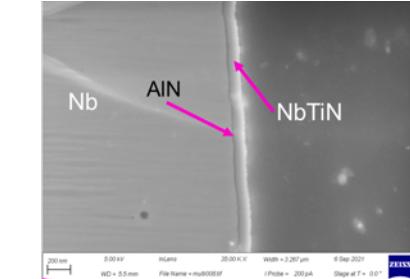
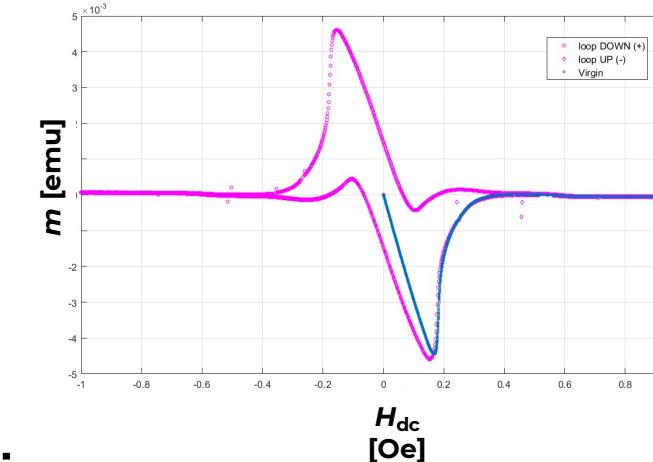
Interesting side effect:

Significant improvement of measurement accuracy (< 4 nW) by coating flanges too.

Ifast WP9 : Thorough material characterization needed!

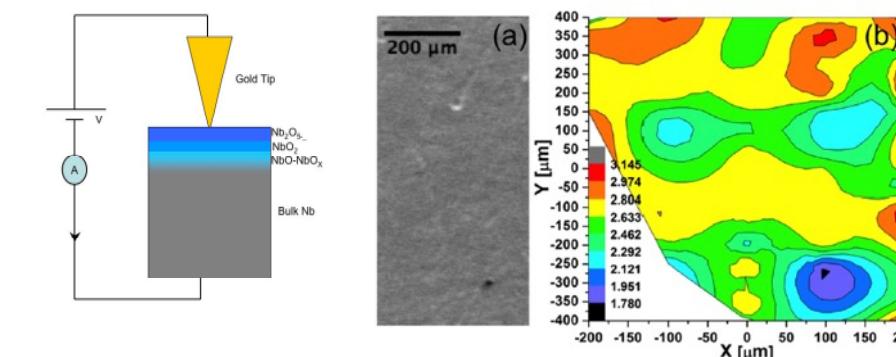
Classical material characterization ...

- Opt. and confocal microscopy
- SEM, EDX and EBSD
- Ion beam miller for cross-section
- X-Ray, TEM ... advanced characterization techniques
- Superconductivity: T_c, RRR, DC magnetometry, AC susceptibility



Home made (advanced) characterization tools:

- Flux penetration (@ UKRI, @ CEA) ($\Rightarrow E_{acc}$)
- Rs on small samples (7.8 GHz cavity @ UKRI)
- SC gap, DOS cartography
(scanning tunnel microscope @ CEA)



CONCLUSION

- Things are going according to IFAST WP9 plan
- WW: thin films activities = few groups, few resources
- Coordination and exchanges help to derive maximum benefit
- Next generation of SRF material is “en route” with already very nice results on samples
- We hope IFAST WP9 (and collaborators) to bridge the gap between lab R&D and 1rst prototypes development
- If accelerator community wants SRF technology to evolve*, strong investments are needed in the near future

* Change of paradigm, not just mere improvement

IFAST WP9:

- 9 countries
- 15 institutes
- >50 participants

+ Not officially:

CERN, DESY, (task 9.1)



	IFAST WP9 Partners		Leading	Participating
1	CEA (Saclay, France)		WP, Tasks 1 and 4	Task 1, 2, 4, 6
2	CNRS/IN2P3/IJCLab (Orsay, France)			Task 1, 4
3	IEE-SAS (Bratislava, Slovakia)			Tasks 2-6
4	INFN/LNL (Legnaro, Italy)		Task 2	Tasks 1, 2, 3, 5, 6
5	INFN/LASA (Milano, Italy)			Tasks 2, 3
6	Piccoli S.r.l. (Noale (VE), Italy)			Tasks 2, 3
7	Helmholtz-Zentrum Berlin (Berlin, Germany)		Task 6	Tasks 1 and 6
8	RTU (Riga, Latvia)		Task 5	Task 5
9	University Siegen, (Siegen, Germany)			Tasks 2, 3, 6
10	UKRI/STFC/ASTeC (Daresbury, UK)		WP, Tasks 1 and 3	Tasks 1, 2, 3, 5, 6
11	Lancaster University (Lancaster, UK)			Tasks 1 – 3, 6
12	Jlab (Newport News, Virginia, USA)			Tasks 1, 2
13	PTI (Physical-Technical Institute, Minsk, Belarus)			Tasks 1, 2
14	MEPhI (National Research Nuclear University, Moscow, Russia)			Tasks 1 - 3
15	Helmholtz-Zentrum Dresden-Rossendorf (Dresden, Germany)			Tasks 1 – 3, 5



Thanks for your attention!



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